UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/517,963	08/09/2005	Manfred Ratzsch	4385-045850	4385-045850 5607	
28289 THE WERR I	7590 08/16/2007 .AW FIRM, P.C.		EXAMINER		
700 KOPPERS	BUILDING		MCCLENDON, SANZA L		
436 SEVENTI PITTSBURGI	· -		ART UNIT PAPER NUMBER		
	-,	1711	1711		
			MAIL DATE	DELIVERY MODE	
			08/16/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Application No.	Applicant(s)			
Office Action Summary		10/517,963	RATZSCH ET AL.			
		Examiner	Art Unit			
		Sanza L. McClendon	1711			
Dariad fo	The MAILING DATE of this communication app	pears on the cover sheet with the	correspondence address			
Period fo	• •	VICALTA EVALAR AMANTI	1/0) 00 TUBELY (00) DAYO			
WHIC - Exte after - If NC - Failu Any	IORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING Does in the may be available under the provisions of 37 CFR 1.1. If SIX (6) MONTHS from the mailing date of this communication. Of period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing led patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDON	ON. timely filed om the mailing date of this communication. NED (35 U.S.C. § 133)			
Status						
1)⊠	Responsive to communication(s) filed on 09 A	<u>ugust 2005</u> .				
2a) <u></u> ☐	This action is FINAL . 2b)⊠ This action is non-final.					
. 3)□	The state of the s					
	closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11,	453 O.G. 213.			
Disposit	ion of Claims					
5)□ 6)⊠ 7)□	Claim(s) <u>1-19</u> is/are pending in the application. 4a) Of the above claim(s) is/are withdraw Claim(s) is/are allowed. Claim(s) <u>1-6,8,10-16 and 18</u> is/are rejected. Claim(s) <u>7, 9, 17 and 19</u> is/are objected to. Claim(s) are subject to restriction and/or	wn from consideration.				
Applicat	ion Papers					
9)[The specification is objected to by the Examine	r.				
. 10)[The drawing(s) filed on is/are: a) acce	epted or b) objected to by the	Examiner.			
	Applicant may not request that any objection to the		` ,			
11)	Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Ex					
		ammer. Note the attached Offic	e Action of form PTO-152.			
	under 35 U.S.C. § 119					
	Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority documents		a)-(d) or (f).			
	 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 					
	3. Copies of the certified copies of the prior		· · · · · · · · · · · · · · · · · · ·			
	application from the International Bureau		rod in this Hatishal Stage			
* 5	See the attached detailed Office action for a list		/ed.			
Attachmen	• •	🗖 :				
	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948)	4)				
3) 🔽 Infor	mation Disclosure Statement(s) (PTO/SB/08) ir No(s)/Mail Date		Patent Application			

Art Unit: 1711

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-6, 8, 10-16, and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Rave (3,535,148) in view of Shultz et al (6,306,555).

Rave discloses a process for preparing polymerized aminoplast surface coatings using ionizing radiation. Said aminoplast compositions are applied in liquid form in thickness of about 0.15 to about 1.0 mil (.38 to 25.4 μ m). Said aminoplast resin is an etherified aminoplast being the condensation product of an ethylenically unsaturated amide, a polyfunctional amine selected from aminotrazine or urea and an aldehyde such as formaldehyde. ionizing radiation is obtained from sources such as ultraviolet radiation or electron beam radiation. Rave sets forth that if the aminoplast is too viscous for coating as a liquid the composition can be heated to reduce the viscosity. Rave sets forth said liquid composition is applied to a substrate of which travels on a conveyor and passes under the ionizing source. composition can comprise fillers and other polymerizable monomers-see 4:45-49 and 4:55-60. Regarding the limitation "...by irradiation with actinic light at a temperature between the melting point of the amino polycondensate and the thermoinduced decomposition temperature of the light-activatable curing agents...." The examiner deems that this is obvious one would not want to heat the composition above the decomposition temperature of the initiator present because there would be no initiator present to activate the polymerization of the composition. And Rave sets forth that the composition can be heated to reduce the viscosity so the composition can be applied to substrates.

Rave et al differs from the instant invention because it does not teach instant component b1, b2, or b3. However these initiators are known to polymerizable aminoplast resin compositions, such as disclosed by Shultz et al. Shultz et al negative photoresist composition that can be developed in

Application/Control Number: 10/517,963

Page 3

Art Unit: 1711

an alkaline medium. Said composition comprises an alkali-soluble resin, a component that undergoes crosslinking, and a photosensitive acid donor compound. Said preferable crosslinkable components are amino resins, such as etherified and non-etherified melamine, urea, quanidine or biuret resins-see [0304]. The photosensitive acid donor can be a iodonium salt, wherein Shultz et al sets forth compounds such as other onium salts, such as sulfonium, phosphonium. diazonium. and pyridinium salts. halogenated sulfonate compounds, and quinonediazide compounds. Rave and Shultz et al are analogous art because they are from the same field of endeavor that is the art of photocationic curable compositions. Therefore it would have been obvious for a skill artisan of ordinary level to use the photoinitiators and/or photoinitiator combinations as set forth by Shultz et al to accelerate the compositions as set forth by Rave. The motivation would have been a reasonable expectation of obtaining a faster cure in the absence of evidence to the contrary and/or unexpected results.

Rave does not expressly teach a post-thermal cure of the composition. However post-thermal cures are known to provide a thorough or complete cure of irradiated compositions. Therefore the examiner deems that a post-thermal is within the skill level of an ordinary artisan to provide a post-thermal cure to the composition of Rave the motivation would have been a reasonable expectation of obtained a complete cure in the absence of evidence to the contrary and/or unexpected results.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an

Application/Control Number: 10/517,963

Page 4

Art Unit: 1711

application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

4. Claims 10-16 and 18 are rejected under 35 U.S.C. 102(b) as being anticipated by Rave (3,535,148).

Rave sets forth irradiated aminoplast coatings obtained by irradiating aminoplast compositions. Said irradiated coatings appear to anticipate the above listed amino resin products. The courts have upheld where prior art discloses product that appears to be either identical with or only slightly different from product claimed in product-by-process claim; Patent Office can require applicant to prove that prior art products do not necessarily or inherently possess characteristics of his claimed product; whether rejection is based on "inherency" under 35 U.S.C. 102, on "prima facie obviousness" under 35 U.S.C. 103, jointly or alternatively, burden of proof is same; Patent Office that has reason to believe that functional limitation asserted to be critical for establishing novelty in claimed subject matter may, in fact, be inherent characteristic of prior art, possesses authority to require applicant to prove that subject matter shown to be in prior art does not possess characteristic relied on.

Claim Rejections - 35 USC § 102/35 USC § 103

5. Claims 1-6 and 9-16 are rejected under 35 U.S.C. 102(b) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Shultz et al (2003/0036591 and 6,306,555).

Shultz et al sets forth negative photoresist compositions that are developable in alkaline mediums. Said composition comprises an alkalisoluble resin, a component that undergoes crosslinking, and a photosensitive Said preferable crosslinkable components are amino acid donor compound. resins, such as etherified and non-etherified melamine, urea, guanidine or biuret resins-see [0304]. The photosensitive acid donor can be a iodonium salt, wherein Shultz et al sets forth compounds such as other onium salts, such as sulfonium, phosphonium, diazonium, and pyridinium salts, halogenated triazines, sulfonate compounds, and quinonediazide compounds. Additionally, Shultz et al sets forth radiation curable compositions comprising (a1) a cationically or acid-catalytically polymerizable or crosslinkable compound, (a2) a compound that increases its solubility in a developer under the action of an acid and (b) at least one diaryl iodonium salt photoinitiator having the structure of general formula (I)-see [0004] to [0006]. compounds can be aminoplast, wherein etherified and non-etherified amino

Art Unit: 1711

resins, such as melamine, urea, guanidine and biuret resin, are preferred for surface coatings—see [0056]. Shultz et al set forth maleic anhydride copolymers as solubility increasers (a2)—see [0912]. Additives such as fillers and the like can be added—see [0198]—wherein silica, zinc oxides, and iron oxides among others can be found. Said compositions can be applied to substrate in thickness of 0.1 to 100 micrometers—see [0227]. Shultz et al does not expressly teach compositional amounts for (a1), (a2) and (b), however it has been upheld by the courts that discovering optimum values of result effective variables involves only routine skill in the art. The composition is applied to a substrate, heating from 60 to 160 OC, carrying out image—wise exposure via irradiation, and optionally post curing at a temperature from 60 to 160 OC, and subsequently developing with a solvent or alkaline developer.

Allowable Subject Matter

- 6. Claims 7, 9, 17 and 19 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 7. The following is a statement of reasons for the indication of allowable subject matter: the amino resin of claim 7 was not found in processes according to claim 1 in the prior art. The prior art failed to disclosed filaments and fibers obtained by the process according to claim 1.

Conclusion |

8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Kirk et al (5,236,472) sets forth abrasive products using aminoplast binders that have been cured by radiation. Habrich et al (4,880,662 and 4,970,399) set forth UV hardenable reactions of which can comprise aminoplast resins and photoinitiators. Irving et al sets forth iodosyl salts and teaches said salts can photocure aminoplast resins. Yamamoto et al (2004/00531358) sets forth photoresist compositions that can comprise aminoplast resins and photoinitiators as instantly claimed.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sanza L. McClendon whose telephone number is (571) 272-1074. The examiner can normally be reached on Monday through Friday 7:30-4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, James Seidleck can be reached on (571) 272-1078. The

Application/Control Number: 10/517,963

Art Unit: 1711

optication, control Number. 10/317, 303

fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Examiner

Art Unit 1711

Page 6

SMC